## Electrochemistry of Polyacetylene, $(CH)_x$ : Electrochemical Doping of $(CH)_x$ Films to the Metallic State

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Summary When silvery films of the semiconducting polymer, cis-'polyacetylene,'  $(CH)_x$ , are used as the anode in the electrolysis of aqueous KI solutions or methylene chloride solutions of  $[Bun_4N]^+[ClO_4]^-$ , films of  $(CHI_y)_x$  and  $[CH(ClO_4)_y]_x$ , respectively, are obtained which, for the compositions  $[CHI_{0.07}]_x$  and  $[CH(ClO_4)_{0.0645}]_x$  have high conductivities characteristic of the metallic state.

THE semiconducting polymer 'polyacetylene,'  $(CH)_{\alpha}$ , can be doped by various vapours or solutions to yield at first either p- or *n*-type semiconductors and ultimately films

exhibiting the electronic properties of metals.<sup>1-3</sup> We report here the first electrochemical studies of  $(CH)_x$  films. The results indicate a new, simple, general method for doping  $(CH)_x$  with a wide range of chemical species.

It was found that when a 1 cm  $\times$  3 cm  $\times$  0.01 cm strip of (CH)<sub>x</sub> film (ca. 82% cis-isomer) was used as the anode in the electrolysis of aqueous 0.5 M KI solution with a potential of 9 V it was doped during ca. 0.5 h to the metallic state, to give, by elemental analysis, (CHI<sub>0.07</sub>)<sub>x</sub>. The current increased from 1 to 43 mA during this time. It is important to note that the flexible, golden-silvery films contained no

oxygen (total C, H, and I content 99.8%) and hence had undergone no hydrolysis and/or oxidation during the electrolytic doping process. The room temperature conductivity of the initial film was ca. 1 imes 10<sup>-8</sup>  $\Omega^{-1}$  cm<sup>-1</sup> and that of the doped film was  $9.7 \ \Omega^{-1} \ \mathrm{cm^{-1}}$ . This value is consistent with that previously observed for  $(CH)_x$  films doped with iodine to the same extent<sup>3</sup> by exposure of the  $(CH)_{x}$  films to iodine vapour. Under the conditions employed, the film was not doped to as high levels, ca.  $[CHI_{0.2}]_x$ , as attained through vapour phase doping. It was shown in a separate experiment, using appropriate amounts of [CHI<sub>0.19</sub>] and 0.5 M KI solutions, that part of the iodine was removed from the film to give material of composition  $[CHI_{0.11}]_x$ . The doped film apparently enters into equilibrium with the KI solution according to equation (1).

$$[\mathrm{CHI}_{0.19}]_{x} + 0.04\mathrm{KI} \rightleftharpoons [\mathrm{CHI}_{0.11}]_{x} + 0.04\mathrm{KI}_{3}$$
(1)

When the  $(CH)_x$  was used as the anode in the electrolysis of 0.5 M [Bun<sub>4</sub>N]+[ClO<sub>4</sub>]<sup>-</sup> in CH<sub>2</sub>Cl<sub>2</sub> at 9 V, doping occurred during ca. 1 h to give flexible films which, by elemental analysis, had the composition  $[CH(ClO_4)_{0.0645}]_x$ . The current increased from 0.95 to 3.4 mA during this time. The resulting room temperature conductivity (four-probe technique) was 970  $\Omega^{-1}$  cm<sup>-1</sup>. Lower doping levels obtained during shorter electrolysis times gave material having conductivities in the semiconductor region. Raman studies show that the iodinated<sup>4</sup> and brominated<sup>2</sup> films should be formulated as  $[(CH)^{+y}(X_3)_y^{-}]_x$  where X = Br or I. By analogy, we believe that  $[CH(ClO_4)_{0.0645}]_x$  is probably the

ionic polycarbonium perchlorate,  $[(CH)^{+0.0645}(ClO_4)^{-}_{0.0645}]_x$ . Similar results were obtained by the electrolysis of methylene chloride solutions of  $[Bun_4N]^+[SO_3CF_3]^-$  and  $[Prn_3^-$ NH]+[AsF<sub>6</sub>]<sup>-</sup>, both of which gave highly conducting golden-silvery flexible films. The former is assumed to contain the  $SO_3CF_3^-$  ion and the latter the  $AsF_4^-$  ion, since elemental analysis of the film gave a composition corresponding to  $[CH(AsF_4)_{0.077}]_x$ . We believe the  $AsF_4^-$  ion is formed by a reaction sequence involving proton abstraction from  $[Pr_{3}^{n}NH]^{+}$  by fluorine atoms from AsF<sub>6</sub><sup>-</sup> during the electrolysis process.

Preliminary experiments indicate that when the  $(CH)_x$ films are used as the cathode in the electrolysis of appropriate alkali metal salts in organic solvents *n*-type doping results. Electrochemical oxidation or reduction of the delocalized (CH)  $_x$   $\pi$ -system offers a simple general method for the electrochemical doping of  $(CH)_x$  films to p- or n-type semiconductors or metals with the concomitant introduction of a large variety of stabilizing counter anions or cations. It would appear that many of these materials, e.g. [CH- $(ClO_4)_{0.0645}]_x$ , could not be synthesized by any obvious conventional chemical means. The composition of  $(CH)_{x}$ ,  $(CHI_{0.07})_x$ ,  $[CH(ClO_4)_{0.0645}]_x$ , and  $[CH(AsF_4)_{0.077}]_x$  was confirmed by (C and H), (C, H, and I), (C, H, and Cl), and (C, H, As, and F) analyses, respectively.

We thank Mr. S. C. Gau for assistance with preliminary electrochemical experiments, Mr. Y. W. Park for help with the four-probe conductivity measurements, and the Office of Naval Research for support.

(Received, 2nd February 1979; Com. 096.)

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